

# INTERNATIONAL STANDARD

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**Semiconductor devices - Micro-electromechanical devices -  
Part 4: Generic specification for MEMS**

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## CONTENTS

FOREWORD .....	3
1 Scope .....	5
2 Normative references .....	5
3 Terms, definitions, units and symbols .....	5
4 Standard environmental conditions .....	7
5 Marking .....	7
5.1 Device identification .....	7
5.2 Device traceability .....	7
5.3 Packing .....	7
6 Test schedule .....	8
6.1 General .....	8
6.1.1 Overview .....	8
6.1.2 Eligibility for qualification and capability approval .....	8
6.1.3 Primary stage of manufacture .....	8
6.1.4 Formation of inspection lots .....	8
6.1.5 Structurally similar device .....	8
6.1.6 Subcontracting .....	8
6.1.7 Incorporated components .....	8
6.1.8 Validity of release .....	8
6.2 Qualification approval procedure .....	8
6.2.1 Qualification approval testing .....	8
6.2.2 Environmental and climatic tests .....	9
6.2.3 Granting of qualification approval .....	9
6.2.4 Statistical sampling procedures .....	11
6.2.5 Endurance tests .....	11
6.2.6 Endurance tests where the failure rate is specified .....	11
6.2.7 Accelerated test procedures .....	12
7 Test and measurement procedures .....	13
7.1 Standard conditions and general precautions .....	13
7.1.1 Standard conditions .....	13
7.1.2 General precautions .....	13
7.1.3 Precision of measurements .....	13
7.2 Physical examination .....	13
7.2.1 Visual examination .....	13
7.2.2 Dimensions .....	13
7.3 Climatic and mechanical tests .....	13
7.4 Alternative test methods .....	13
Annex A (normative) Sampling procedures .....	14
A.1 General .....	14
A.1.1 General .....	14
A.1.2 Selection of samples .....	14
A.1.3 Failures .....	14
A.2 Single-lot sampling method .....	14
A.2.1 General .....	14
A.2.2 Sample size .....	14
A.2.3 Acceptance procedure .....	14

A.3	Multiple criteria .....	14
A.4	100 % inspection .....	14
Annex B (informative) Classification for MEMS technologies and devices .....		15
B.1	Manufacturing process technology .....	15
B.1.1	Basic technology .....	15
B.1.2	Bulk micromachining technology .....	15
B.1.3	Surface micromachining technology .....	15
B.1.4	Assembly and packaging .....	15
B.1.5	LIGA process .....	15
B.1.6	Laser micromachining .....	15
B.1.7	Micro moulding .....	15
B.1.8	Other .....	15
B.2	Assembly (interfacing) technology .....	15
B.3	Applications .....	15
B.3.1	Bio-medical .....	15
B.3.2	Communications .....	16
B.3.3	Consumer electronics .....	16
B.3.4	Automotive .....	16
B.3.5	Environmental .....	16
B.3.6	Defence and space .....	17
B.3.7	Others .....	17
B.4	Test and measurement procedures .....	17
B.4.1	Material properties .....	17
B.4.2	Device and system characteristics .....	18
B.4.3	Other .....	18
Bibliography .....		19
Table 1 – MEMS categories and terms .....		6
Table 2 – Subgrouping for Group B and Group C .....		10

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**Semiconductor devices - Micro-electromechanical devices -  
Part 4: Generic specification for MEMS**

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IEC 62047-4 has been prepared by subcommittee 47F: Micro-electromechanical systems, of IEC technical committee 47: Semiconductor devices. It is an International Standard.

This second edition cancels and replaces the first edition published in 2008. This edition constitutes a technical revision.

This edition includes the following significant technical changes with respect to the previous edition:

- a) in the Scope, optical MEMS, bio-MEMS, micro TAS, and power MEMS for various types of MEMS applications were included;
- b) MEMS categories and terms in Table 1 were slightly modified such consumer electronics and automotive were added that in application technology.

The text of this International Standard is based on the following documents:

Draft	Report on voting
47F/532/FDIS	47F/540/RVD

Full information on the voting for its approval can be found in the report on voting indicated in the above table.

The language used for the development of this International Standard is English.

A list of all parts in the IEC 62047 series, published under the general title *Semiconductor devices - Micro-electromechanical devices*, can be found on the IEC website.

This document was drafted in accordance with ISO/IEC Directives, Part 2, and developed in accordance with ISO/IEC Directives, Part 1 and ISO/IEC Directives, IEC Supplement, available at [www.iec.ch/members\\_experts/refdocs](http://www.iec.ch/members_experts/refdocs). The main document types developed by IEC are described in greater detail at [www.iec.ch/publications](http://www.iec.ch/publications).

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## 1 Scope

This part of IEC 62047 describes generic specifications for micro-electromechanical systems (MEMS) made by semiconductors, which are the basis for specifications given in other parts of this series for various types of MEMS applications such as sensors, RF MEMS, optical MEMS, bio-MEMS, micro TAS, and power MEMS. This document specifies general procedures for quality assessment and establishes general principles for describing and testing of electrical, optical, mechanical and environmental characteristics.

This part of IEC 62047 aids in the preparation of standards that define devices and systems made by micromachining technology, including but not limited to, material characterization and handling, assembly and testing, process control and measuring methods. MEMS described in this document are basically made of semiconductor material. However, the statements made in this document are also applicable to MEMS using materials other than semiconductor, for example, polymers, glass, metals and ceramic materials.

## 2 Normative references

The following documents are referred to in the text in such a way that some or all of their content constitutes requirements of this document. For dated references, only the edition cited applies. For undated references, the latest edition of the referenced document (including any amendments) applies.

IEC 60027 (all parts), *Letter symbols to be used in electrical technology*

IEC 60050-523, *International Electrotechnical Vocabulary (IEV) - Part 523: Micro-electromechanical devices* (available at [www.electropedia.org](http://www.electropedia.org))

IEC 60068-2 (all parts), *Environmental testing - Part 2: Tests*

IEC 60617, *Graphical symbols for diagrams*

IEC 61193-2, *Quality assessment systems - Part 2: Selection and use of sampling plans for inspection of electronic components and packages*

IEC 62047-1, *Semiconductor devices - Micro-electromechanical devices - Part 1: Terms and definitions*

ISO 2859-1:1999, *Sampling procedures for inspection by attributes - Part 1: Sampling schemes indexed by acceptance quality limit (AQL) for lot-by-lot inspection*  
ISO 2859-1:1999/AMD1:2011

ISO 80000-1, *Quantities and units - Part 1: General*

## 3 Terms, definitions, units and symbols

For the purposes of this document, the following terms, definitions, units and symbols apply.

ISO and IEC maintain terminology databases for use in standardization at the following addresses:

- IEC Electropedia: available at <https://www.electropedia.org/>
- ISO Online browsing platform: available at <https://www.iso.org/obp>